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Rice processing apparatus detects and adjusts the moisture content of polished rice

Patent Assignee: YAMAMOTO SEISAKUSHO KK (YAMA-N)

Number of Countries: 001 Number of Patents: 002

Patent Family:

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JP 2001113186	A	20010424	JP 99298276	A	19991020	200140 B
JP 3194918	B2	20010806	JP 99298276	A	19991020	200147

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Patent Details:

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Abstract (Basic): JP 2001113186 A

NOVELTY - A detector (16) determines the moisture content in polished rice in drier (61). A control unit (86) adjusts the moisture content of rice based on the output of the detector.

USE - Rice processing apparatus.

ADVANTAGE - Crack generation on the rice surface can be prevented. Fungus generation or decay of rice is prevented and the shelf-life is increased. Also the rice does not need to be rinsed prior to cooking.

DESCRIPTION OF DRAWING(S) - The figure shows the vertical front view of the rice processing apparatus. (Drawing includes non-English language text).

Detector (16)

Drier (61)

Control unit (86)

pp; 10 DwgNo 1/5

Title Terms: RICE; PROCESS; APPARATUS; DETECT; ADJUST; MOIST; CONTENT; POLISH; RICE

Derwent Class: D13; P41

International Patent Class (Main): B02B-001/08

International Patent Class (Additional): A23L-001/10; B02B-001/06

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